課程委員會議通過修訂日期: 2011/9/2 updated: (year)/(month)/(day)

							updated: (year)/(month)/(
課程名稱	(中) 高	等薄膜製程	(M054	)			
(course name)	(Eng.) Advanced Thin Film Processing						
開課系所班級 (dept. & year)	材料系研究所		學分 (credit	s)	3	授課教師 (teacher)	林克偉
課程類別 (course type)	□必修(Mandatory) ■選修(Elective)		授課語 <sup>·</sup> (langua <sub>i</sub>		中文	開課學期 (semester)	下學期
課程簡述 (course description)	(中) 薄膜是實踐電子元件輕薄短小、低損耗能量之關鍵技術,也使得固態電子產品能精確控制其品質。本課程除了介紹各種物理氣象沉積法(PVD)、化學氣象沉積法(CVD)及真空原件之原理應用外,也將介紹利用熱力學與動力學觀點來探討薄膜的成長機制。 (Eng.) Thin film technology is largely utilized in that it is a part of other technologies that are central to analysis, research, development, and manufacturing. This course will focus on kinds of methods for PVD、CVD technology、principle and applications of vacuum equipment, and discusses the mechanism of thin film nucleation using the rmodynamic and kinetic theory.						
先修課程名稱 (prerequisites)							
課程目標與核心能力關聯配比(%) (relevance of course objectives and core learning outcomes)  課程目標之教學方法與評量: (teaching and assessment methods for course objective							nd assessment
課程目標(中	/Eng.)	核心能力		酉	记比(%)	教學方法	評量方法
學生可藉由此課程了解 薄膜製程之基本原理與 其重要性,未來學生投入 職場時也可學以致用,與 產業界結合。 Student can make use of this course to understand the basic principle of thin film process and its importance. Student can put into practice what has been learned when they get a job in the future.		■1.特定材料之專業 知識 □2.策劃及執行專題 研究之能力 □3.撰寫專業論文之 能力 ■4.創新思考、解決問 題與終身學習之能力 □5.跨領域協調整合 之能力 □6.國際觀及綠色材 料知識 □7.領導、管理及規劃 之能力		50		講授作	測驗實作
授課內容(單元名稱與內容、習作/考試進度、備註) (course content and homework/ tests schedule)							
01 Kinetic theory 02 Vacuum syste 03 Thin-film eva 04 Film thickness 05 Physics of spu	of gas m poration pro s uniformity	ocess		l			

- 06 Plasma and ion beam processing of thin-film / Operation#2
- 07 Midterm exam
- 08 DC,AC, and reactive sputtering processes / Operation#3
- 09 Plasma etching
- 10 Midterm exam / Operation#4
- 11 CVD introduction
- 12 Thermodynamics of CVD / Operation#5
- 13 An atomic view of substrate surfaces
- 14 Thermodynamic aspects of nucleation / Operation#6
- 15 Kinetic process in nucleation and growth
- 16 Experimental studies of nucleation and growth
- 17 Final presentation
- 18 Final presentation

# 學習評量方式

### (evaluation)

(1) Midterm exam: 30%

(2) Final presentation: 40%

(3) Operation exam: 30%

期中考 (Midterm exam):

目的在評估學生對課堂講授資料的了解程度,並且培養同學平日課後複習的習慣以及思考問題的能力。

期末報告(Final presentation):

選定課程相關的主題進行資料的蒐集與整理,於學期末提出 20 分鐘報告。目的是要提供學生自我學習的機會,培養學生蒐集資料與整理資料的能力,並訓練學生表達與溝通的能力。

操作考試(Operation exam):

由助教講解並讓學生有動手操作真空系統之實作經驗,目的為培養學生真空技術及解決問題的能力。

## 教科書&參考書目(書名、作者、書局、代理商、說明)

# (textbook& other references)

#### 教科書

Materials Science of Thin Films, 2nd, Milton Ohring, Academic Press, (2002). 歐亞書局有限公司 (02-8912-1188)

## 參考書目

Vacuum technology, 3rd ed., A. Roth, Elsevier Science Publishers B. V., (1990). Physics Library

### 課程教材(教師個人網址請列在本校內之網址。)

(teaching aids & teacher's website)

Power point files.

課程輔導時間(office hours)

星期二上午 10:00~12:00